

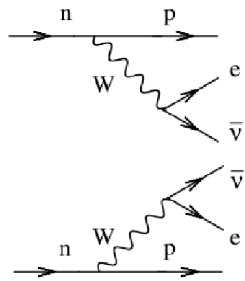
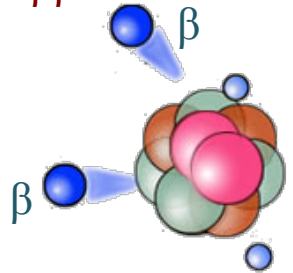
**$0\nu\beta\beta$ search with CMOS pixel charge
plane in gain-less high-pressure gas
Time Projection Chamber**

Yuan Mei
Lawrence Berkeley National Laboratory

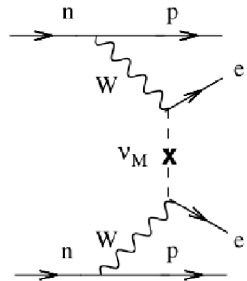
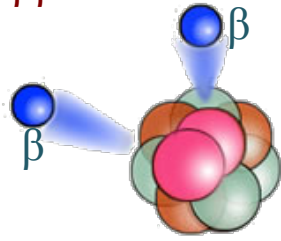
TAUP 2017

Physics Motivation: Neutrinoless Double-Beta Decay

$2\nu\beta\beta$

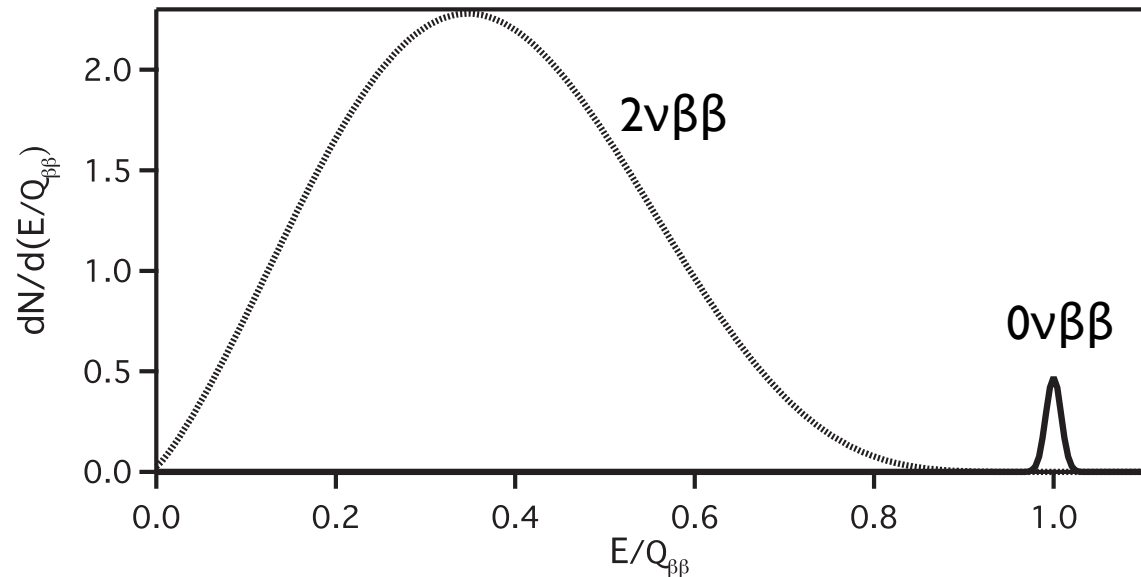
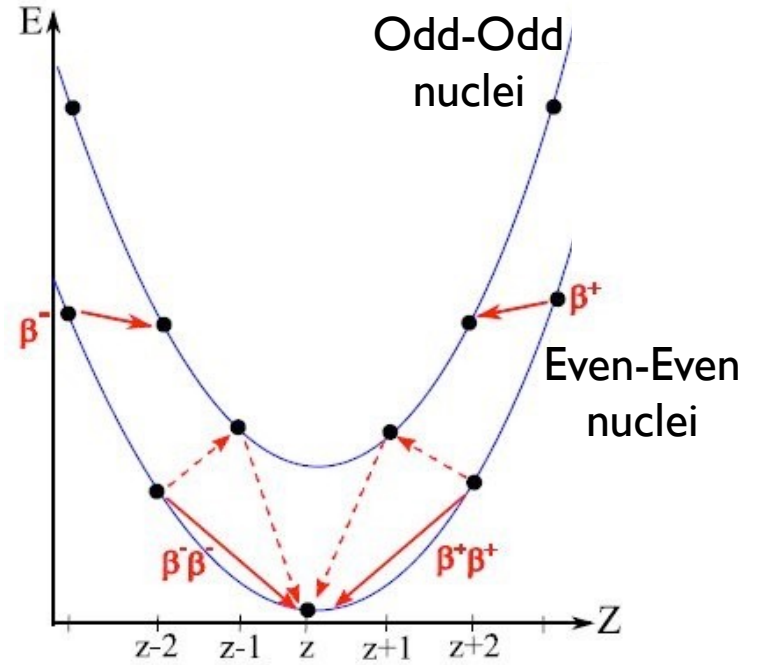
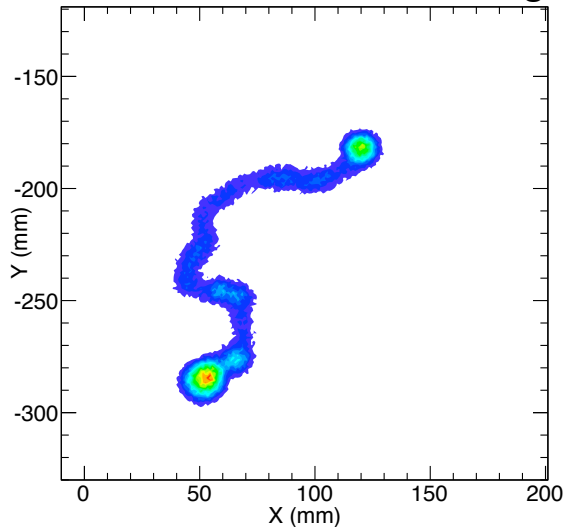


$0\nu\beta\beta$



half-life sensitivity $\propto a \cdot \epsilon \sqrt{\frac{M \cdot t}{b \cdot \delta E}}$

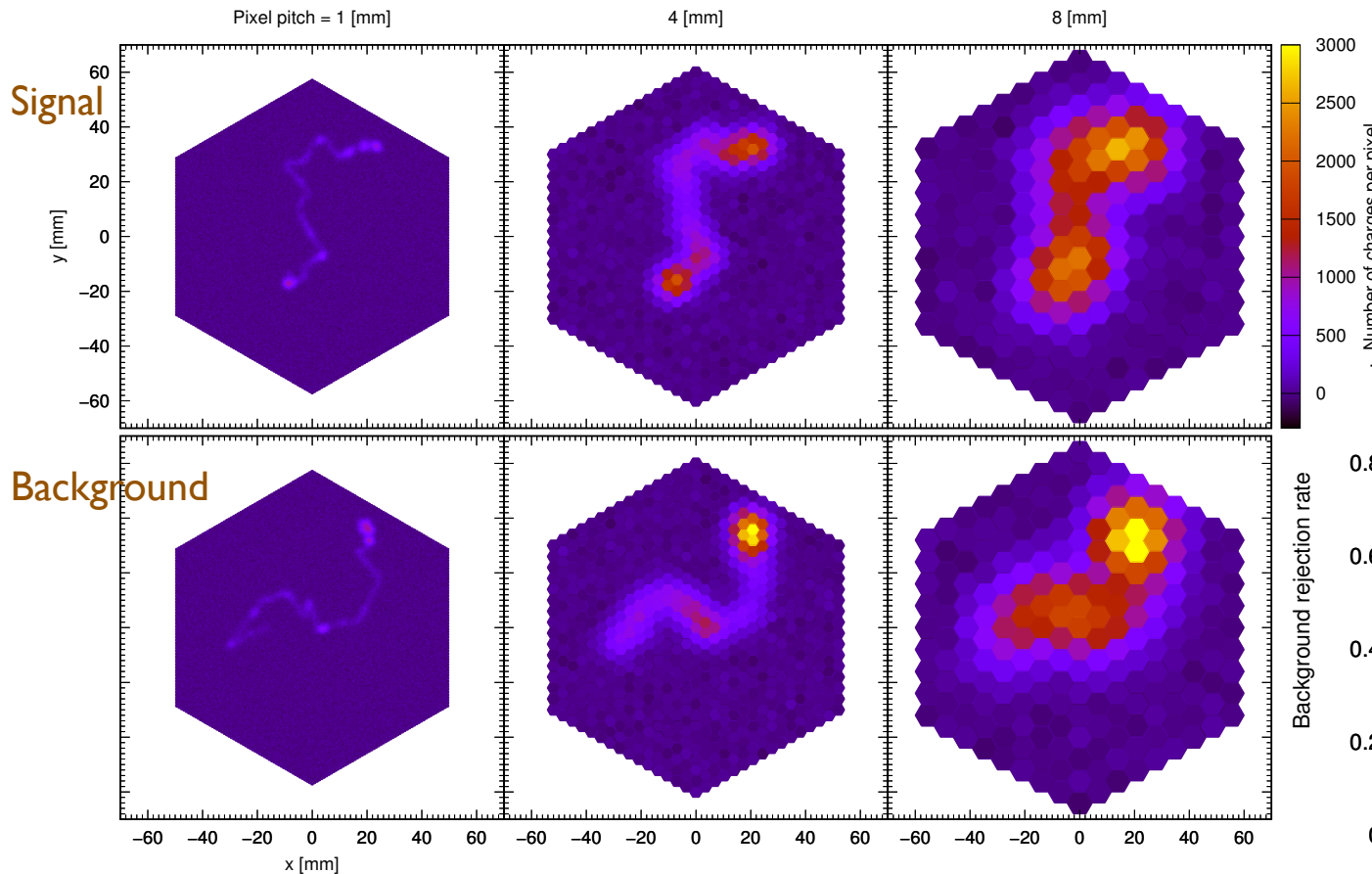
Simulated ^{136}Xe $0\nu\beta\beta$ event, ionization track in 10bar Xe gas



Assumes BR $0\nu/2\nu = 1\%$ and detector energy resolution is 2%

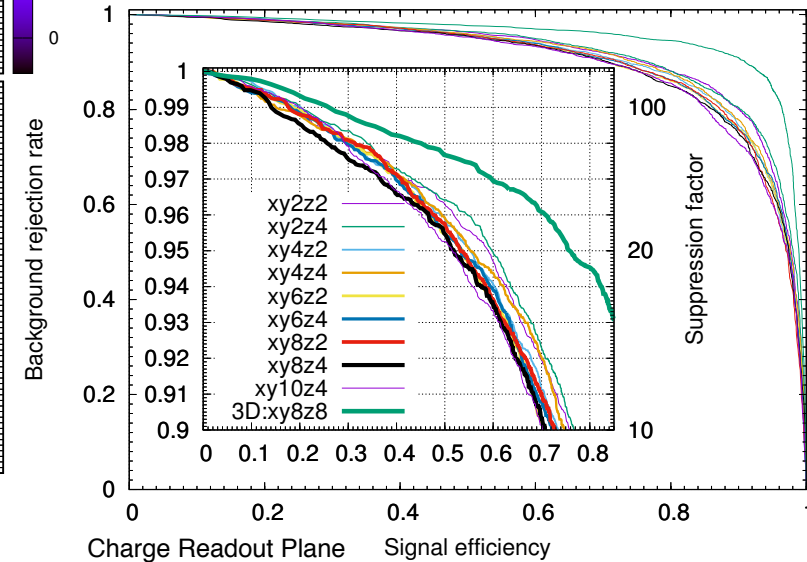
Ionization imaging (3D) for $0\nu\beta\beta$

Simulated events in ^{136}Xe $0\nu\beta\beta$ energy region, ionization track in 10bar Xe gas

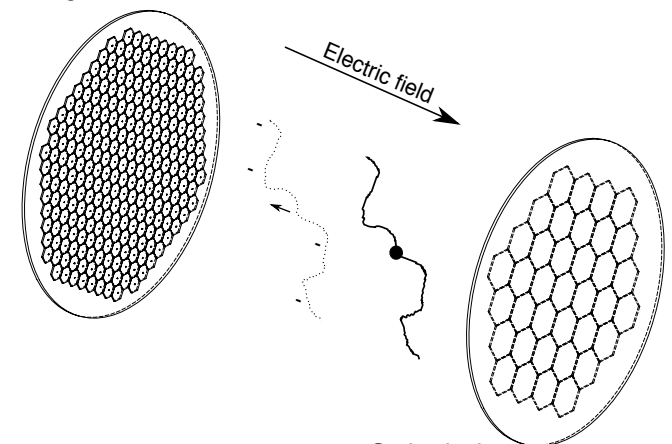
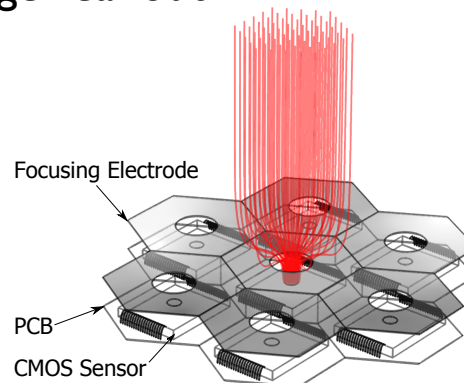
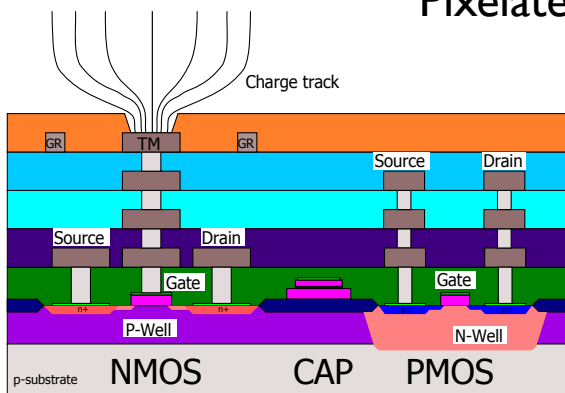


Background discrimination using 3D track pattern information

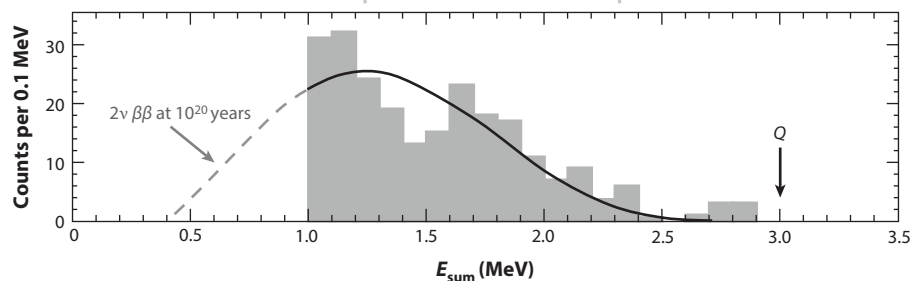
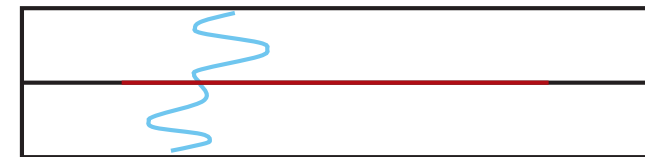
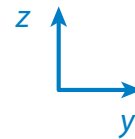
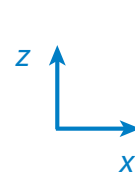
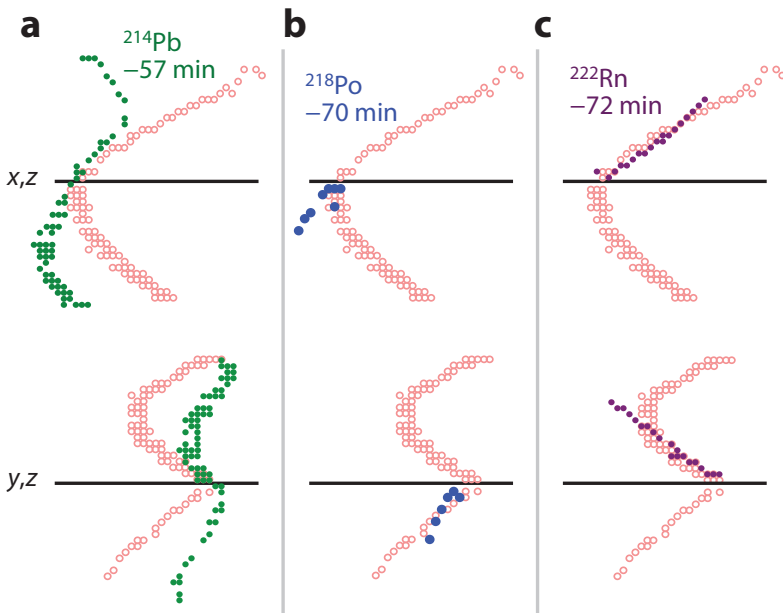
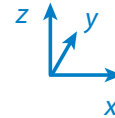
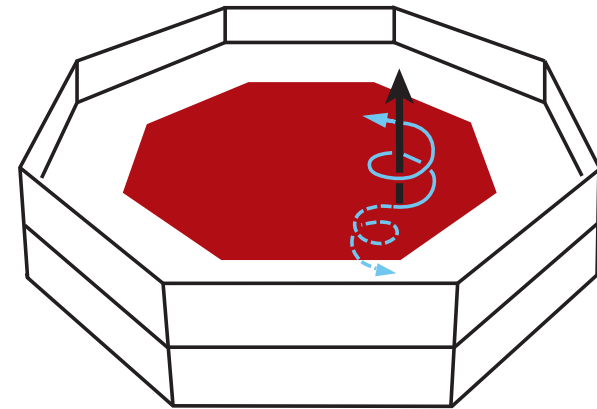
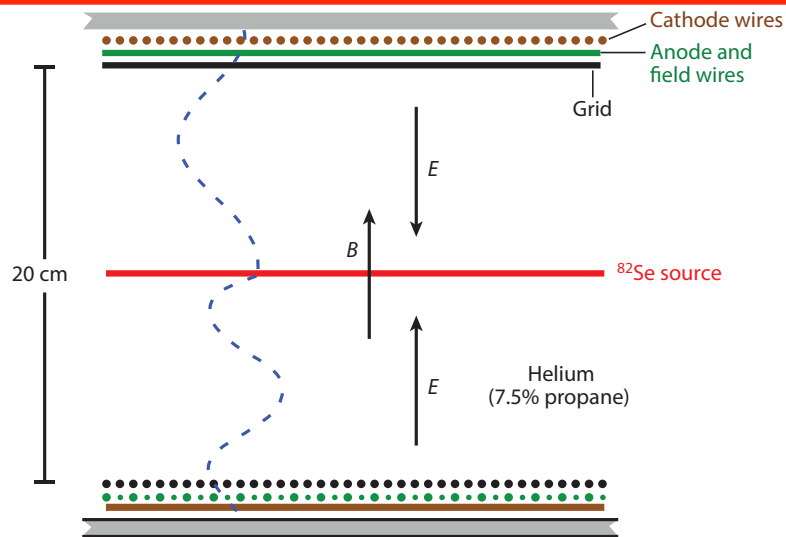
Application of machine learning methods:



Pixelated charge readout



^{82}Se 2ν double-beta decay



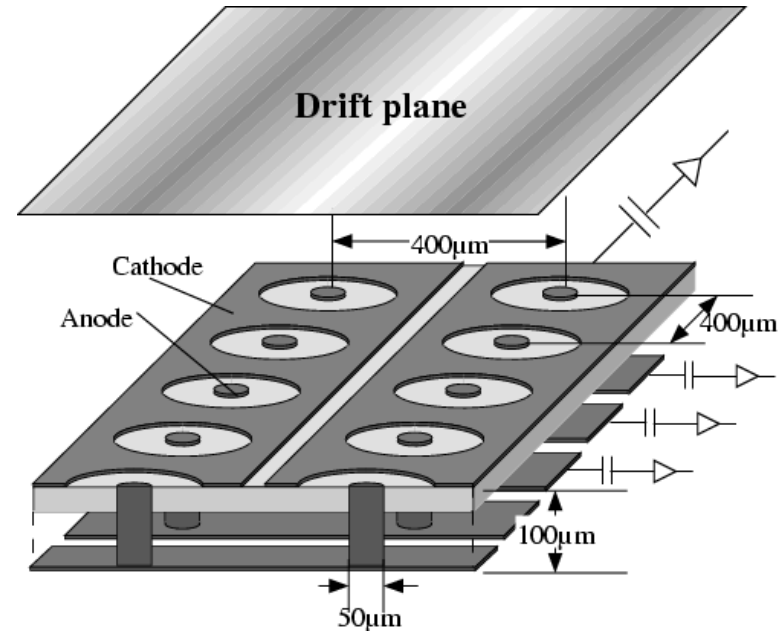
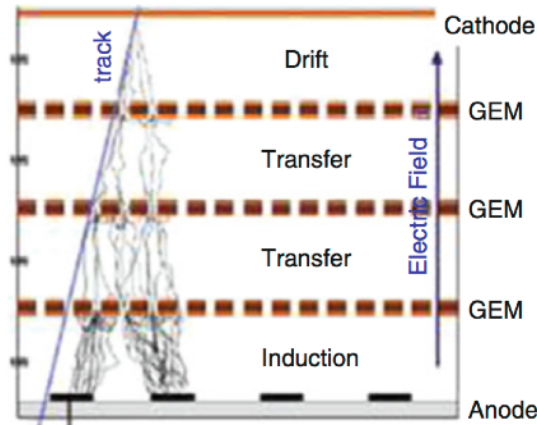
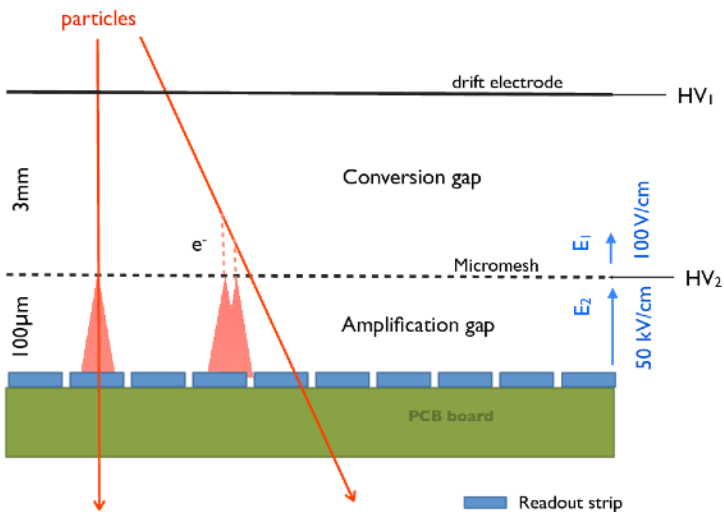
- Michael Moe et. al. circa 1980s
- Thin ^{82}Se source ($\sim 7\text{g}$, 97% enriched) in He gas TPC
- ^{214}Bi background suppression at 96%

Challenges and solutions

To do a definitive experiment

- Scalable to large mass while retaining:
 - Excellent energy resolution at $Q_{\beta\beta}$
 - Background control: pure material and active discrimination
 - Geometrical signature of decay (positive signal identification)
 - Leverage industry to scale
- High pressure gaseous TPC
 - HP Xe has been proven to have excellent intrinsic energy resolution (ionization charge statistics)
 - PandaX-III and NEXT employ Micromegas and electroluminescence techniques to achieve high energy resolution and charge tracking

Gas-electron multiplication, stability?



- **MicroMegas**

- Micromesh placed (very) close to readout PCB

- **GEM**

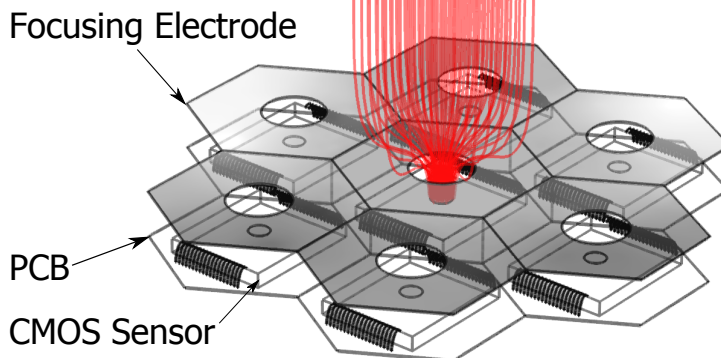
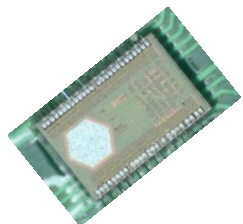
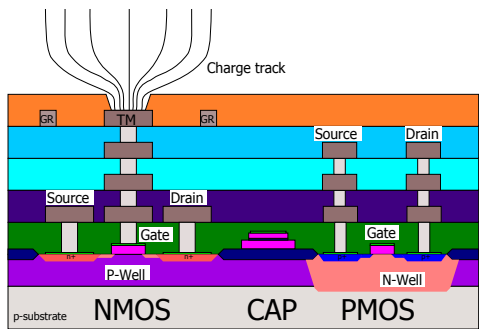
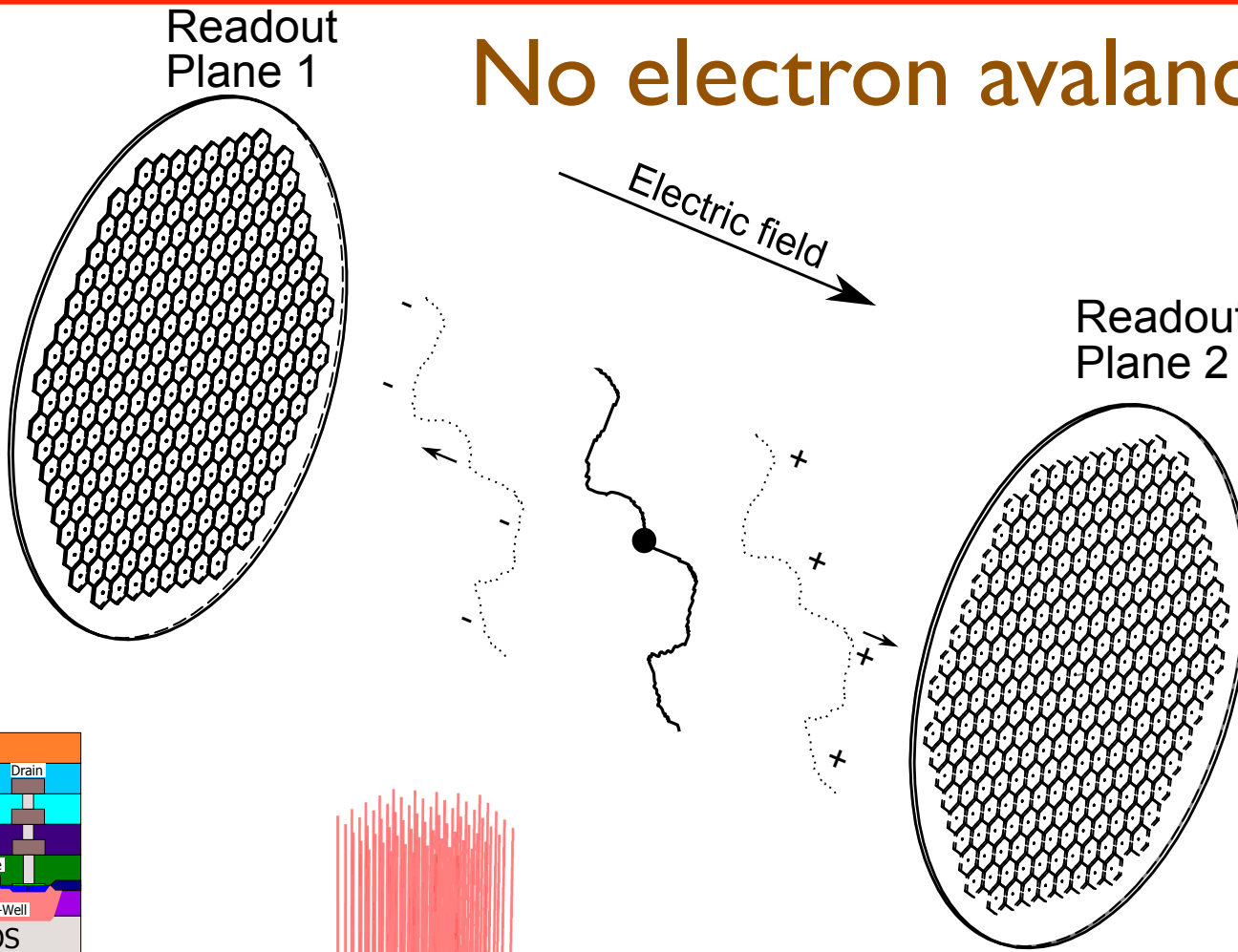
- Array of micro-holes in thin foils with conductor cladding on both sides

- **μ-PIC** (Micro Pixel Chamber)

- Printed Circuit Board technology

CMOS charge sensor array for TPC

No electron avalanche gain!



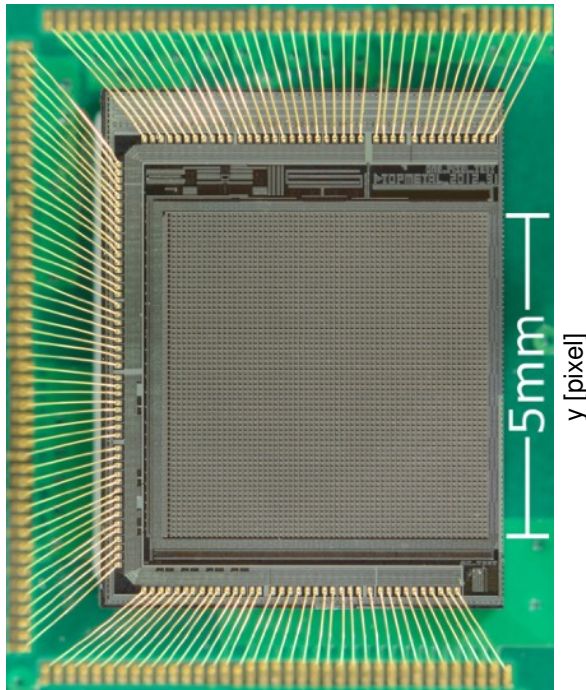
- Eliminate charge amplification
- Focusing electrode 100% coll. eff.
- Direct charge collection in X-Y
- In-sensor digitization
- Inter-sensor network for data readout

Numbers

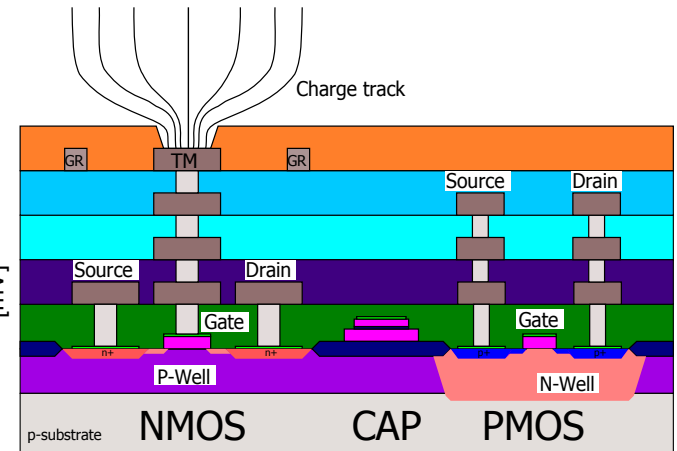
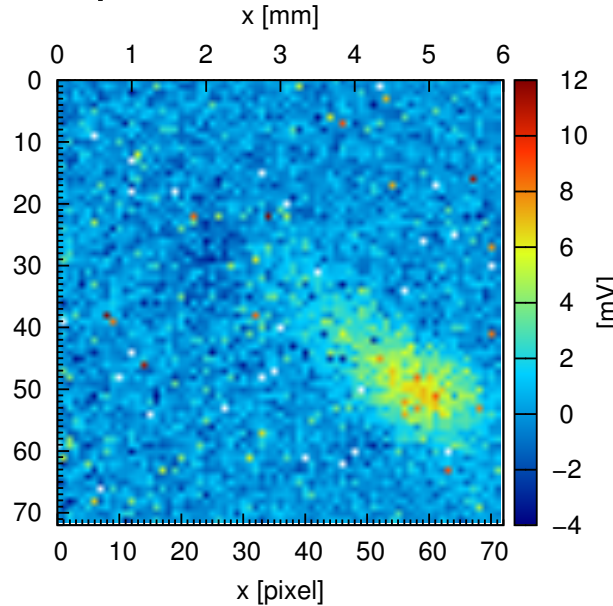
High pressure Xenon TPC as an example

- ~50 free ions/electrons per keV energy deposition
- ^{136}Xe $Q_{\beta\beta}=2.458\text{MeV} \rightarrow 100\text{k}$ charges
- 10bar Xe intrinsic energy resolution: 0.3% FWHM at $Q_{\beta\beta}$
 $\rightarrow 130 e^-$ total fluctuation (σ , detection medium contribution)
- 1% FWHM energy resolution at $Q_{\beta\beta} \rightarrow 420 e^-$ fluctuation (σ)
 $\rightarrow 400 e^-$ electronic noise allowed (sum of all pixels)
- Track length 20~30cm $\rightarrow 300$ pixels see charge if pitch 5~10mm
 $\rightarrow <30 e^-$ per pixel noise required
- 100% charge collection efficiency
 loss of efficiency is equivalent to increasing noise
- 10cm diameter array: ~100 chips
- 1m diameter array: ~10k chips
- Charge drifting speed (sets the sampling rate requirement)
 - Electron: mm/ μs
 - Ion: mm/ms

Topmetal



Alpha ionization tracks



Xiangming Sun

Former LBNL RNC postdoc,

STAR HFT development until 2013

Now Professor, Director of Pixel Lab (PLAC)

Central China Normal University (CCNU)

Yuan Mei

LBNL NSD weak interactions

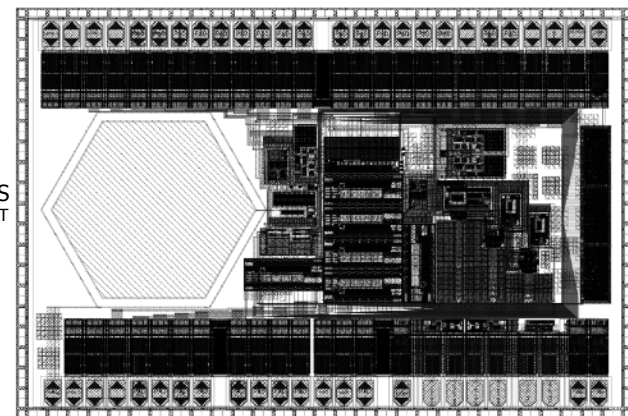
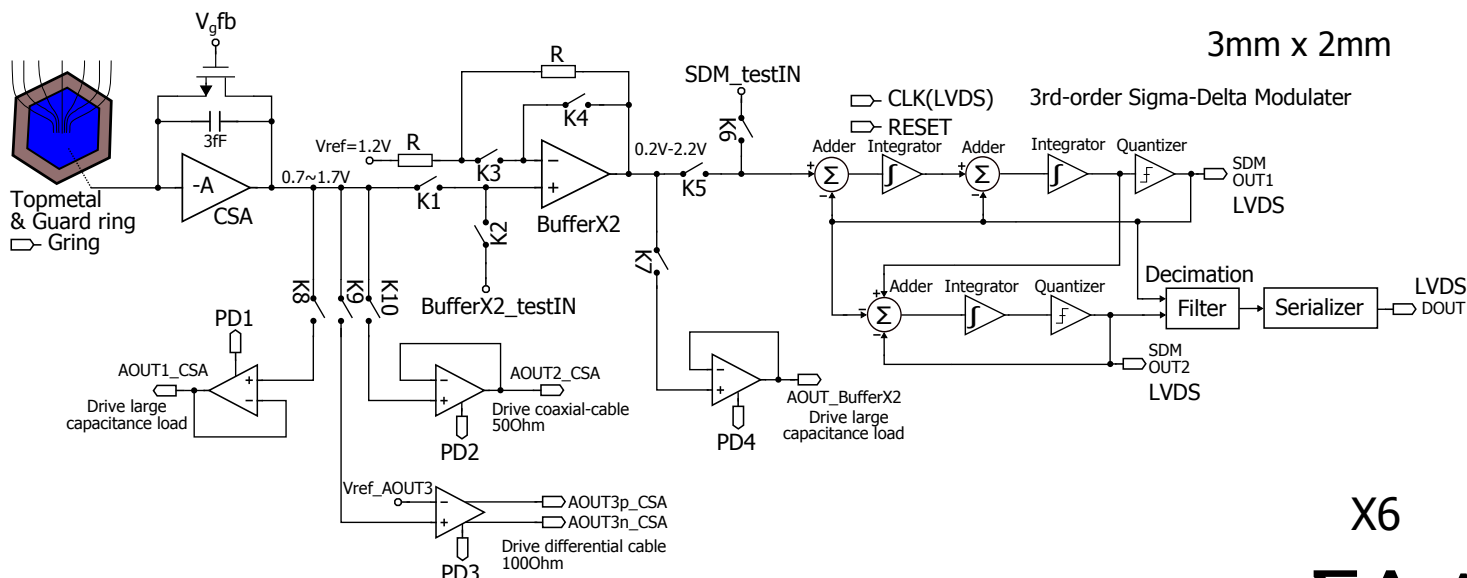
Postdoc (2011–2015)

Staff (2016–)

- $80 \times 80 \mu\text{m}$ pixel size
- Direct charge collection
- Standard $0.35 \mu\text{m}$ CMOS process, no post-processing
- First version (2012), high noise & high bandwidth
- Second version (2014), $< 15e^-$ noise on each pixel. In-chip signal processing, good for large scale array
- Third version (2016), specialized design for $0v\beta\beta$

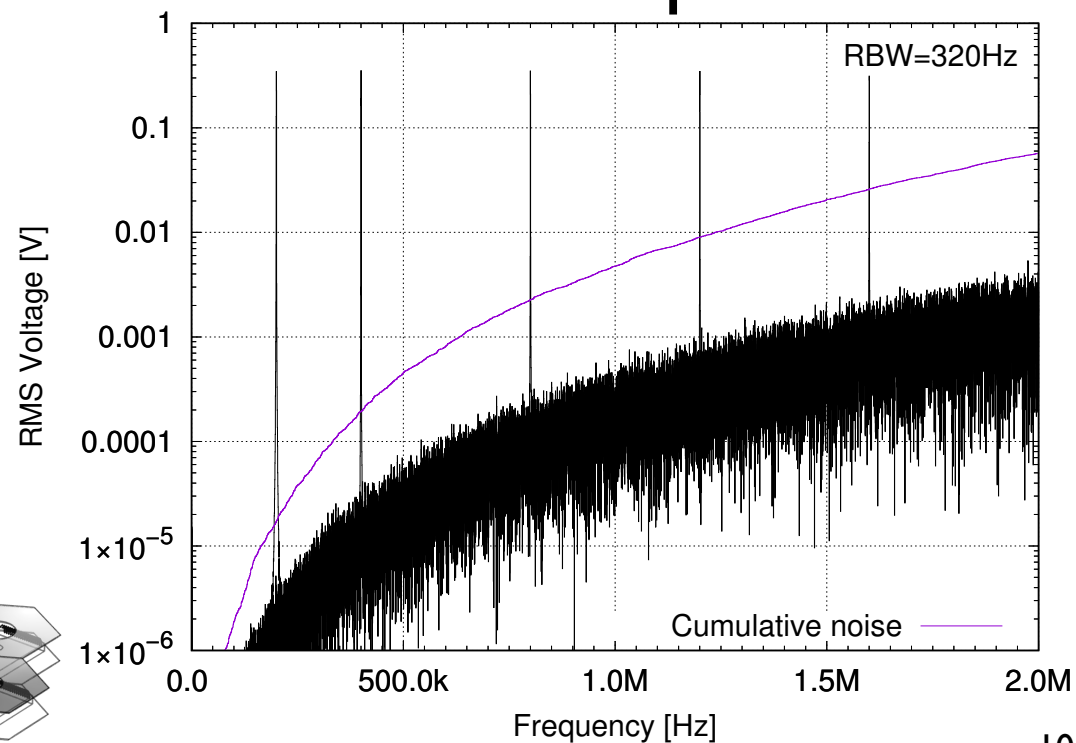
Topmetal-S (2016)

chip layout



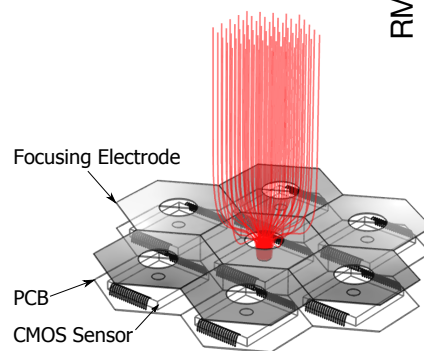
X6

$\Sigma\Delta$ ADC spectrum



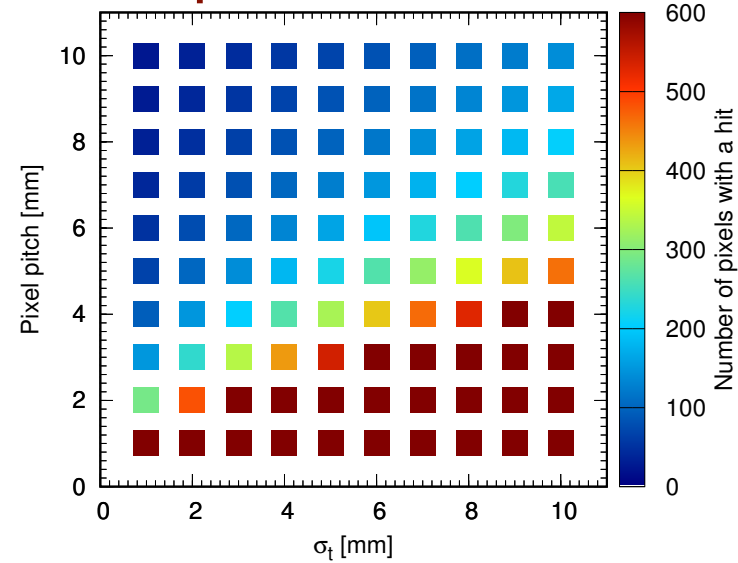
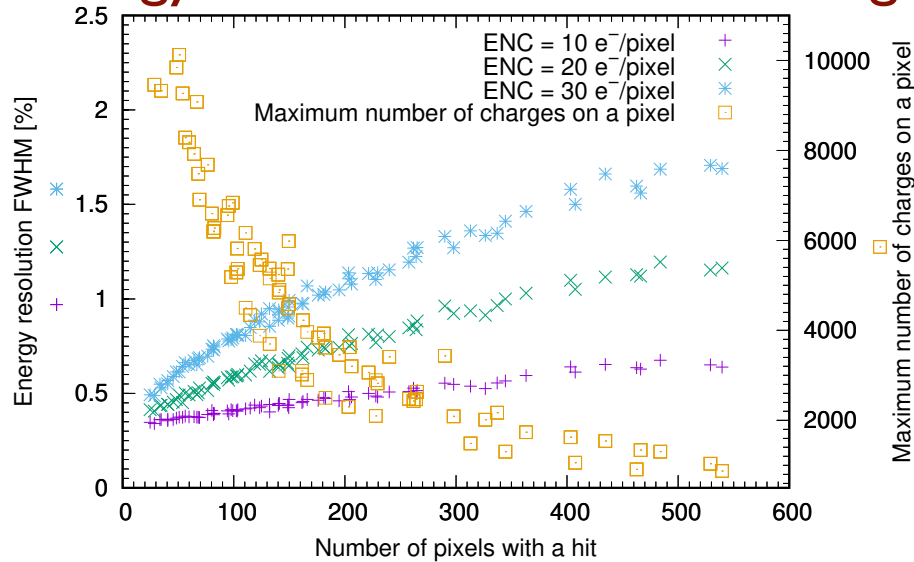
- Single electrode: 1mm dia. *Topmetal* or smaller electrode with externally 'grown' structure
- Distance between chips: 5~10mm
- CSA: $C_{in} \sim 2pF$, $ENC < 30e^-$, tunable biases through DACs
- Tunable feedback RC decay constant
- Directly accessible analog output
- Analog output (X2) feeds into a Sigma-Delta ADC

- 3rd-order Sigma-Delta Modulator
- 25.6MHz clock
- X64 over sampling rate
- SINC4 decimation filter
- 200kHz signal bandwidth
- Equivalent of a 400kps 16bit ADC
- Raw modulator output
- LVDS I/O

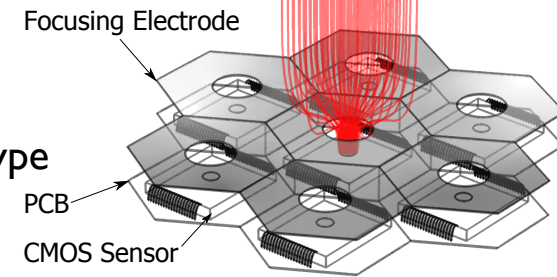


Design optimization (prototype)

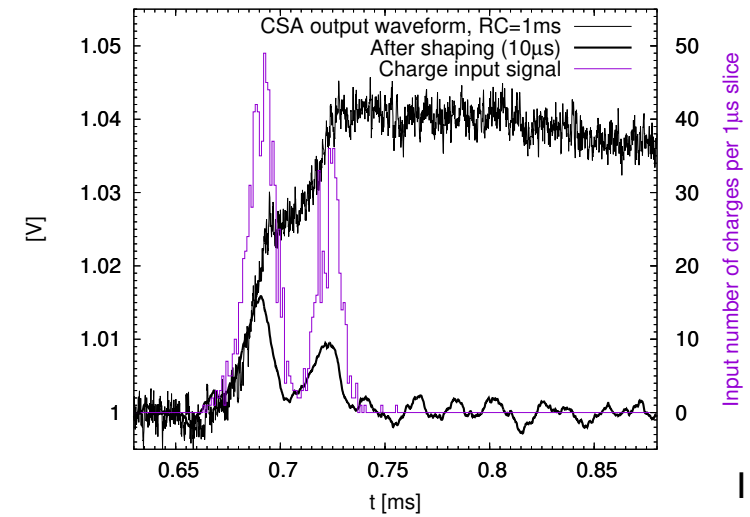
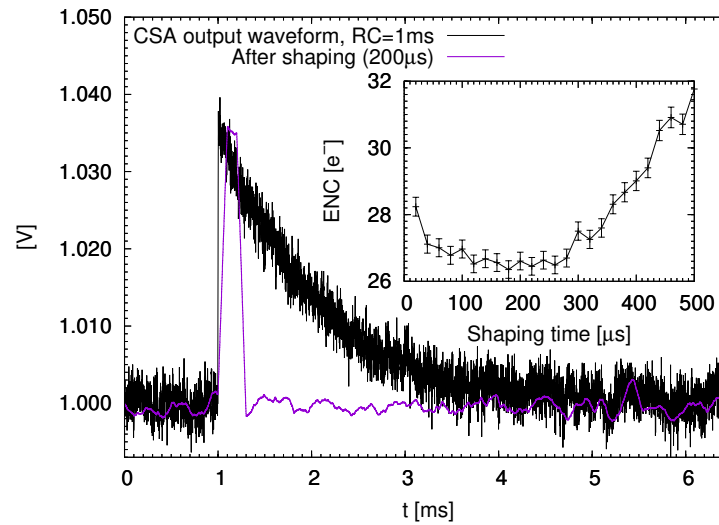
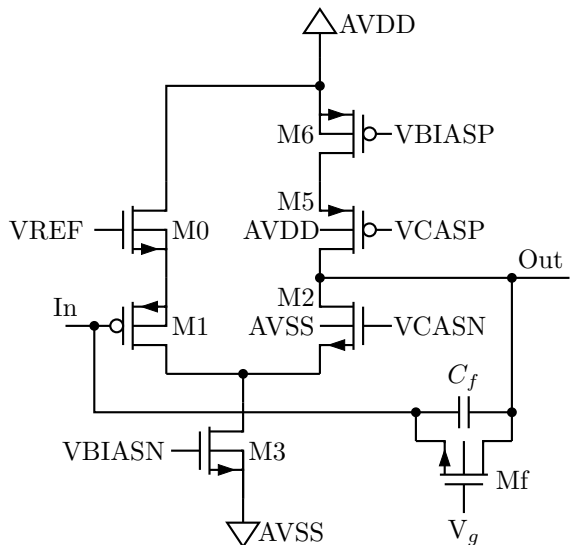
Energy resolution: tradeoff among diffusion, pixel size and noise



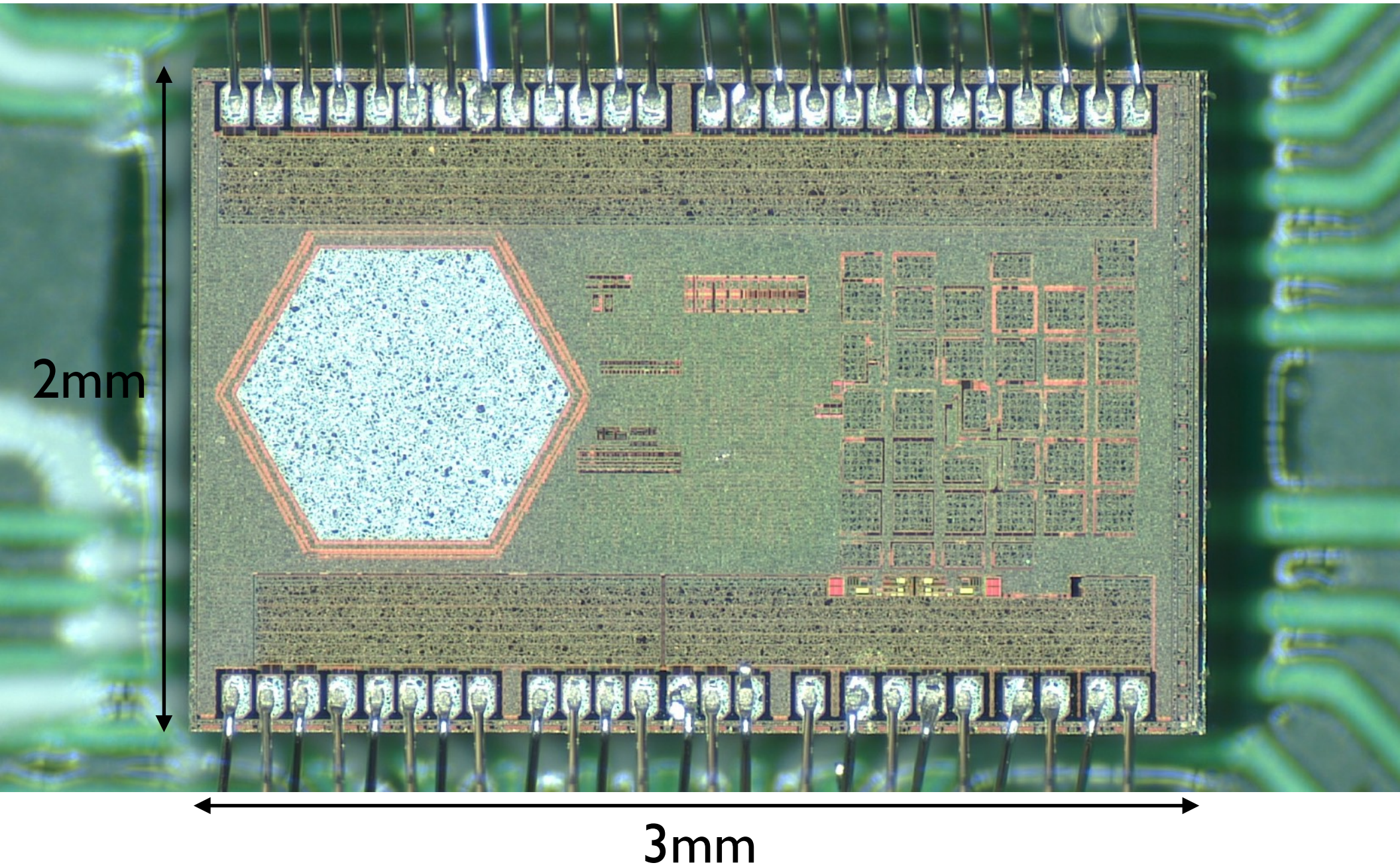
- 1 mm dia. electrode
- 8 mm pitch
- 127 chips on prototype



Charge measurement, noise, and signal recovery

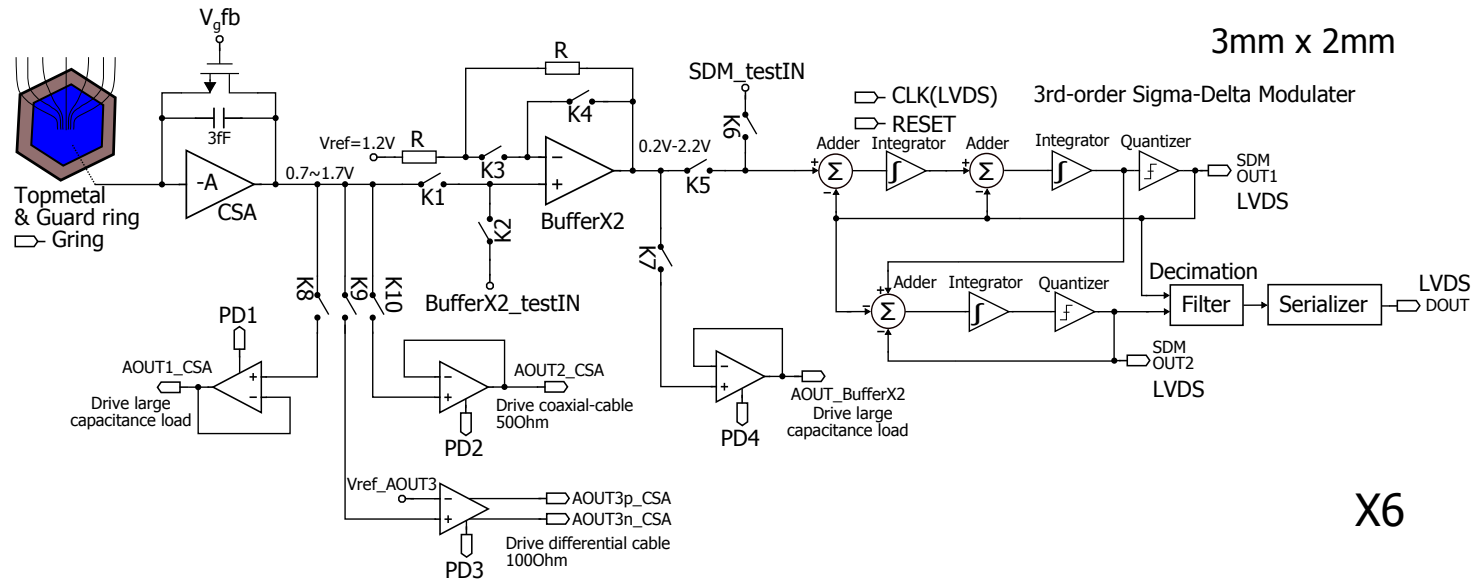
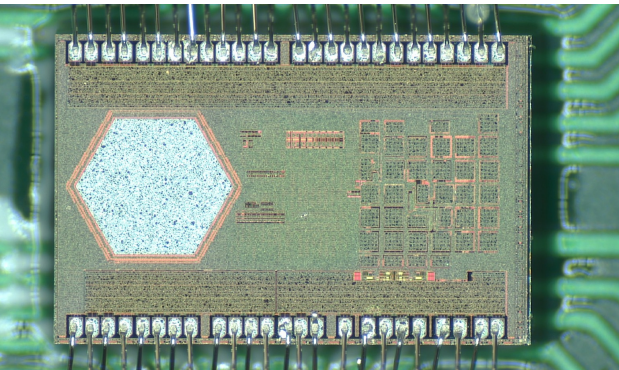


Topmetal-S with 1mm electrode

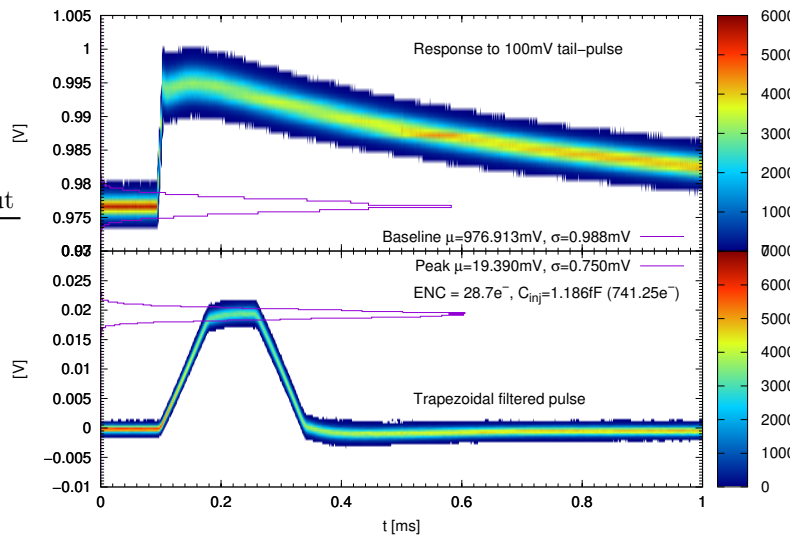
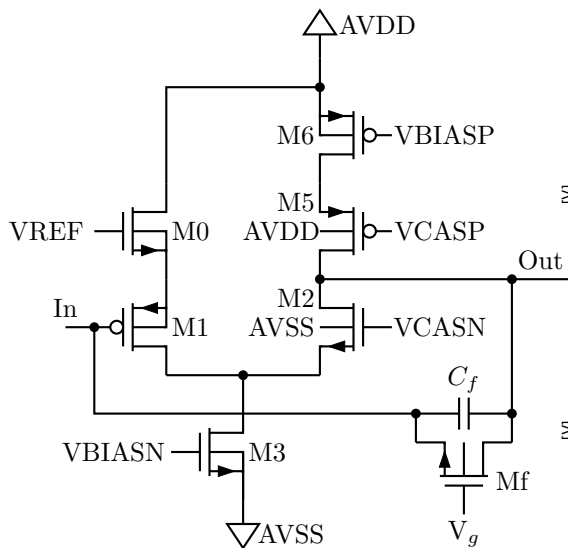


Topmetal-S Performance

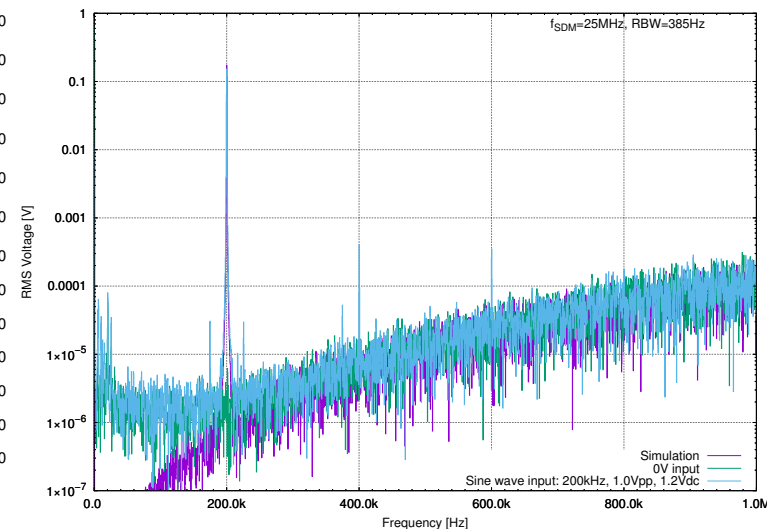
A working Topmetal-S sensor



< 30e⁻ noise CSA

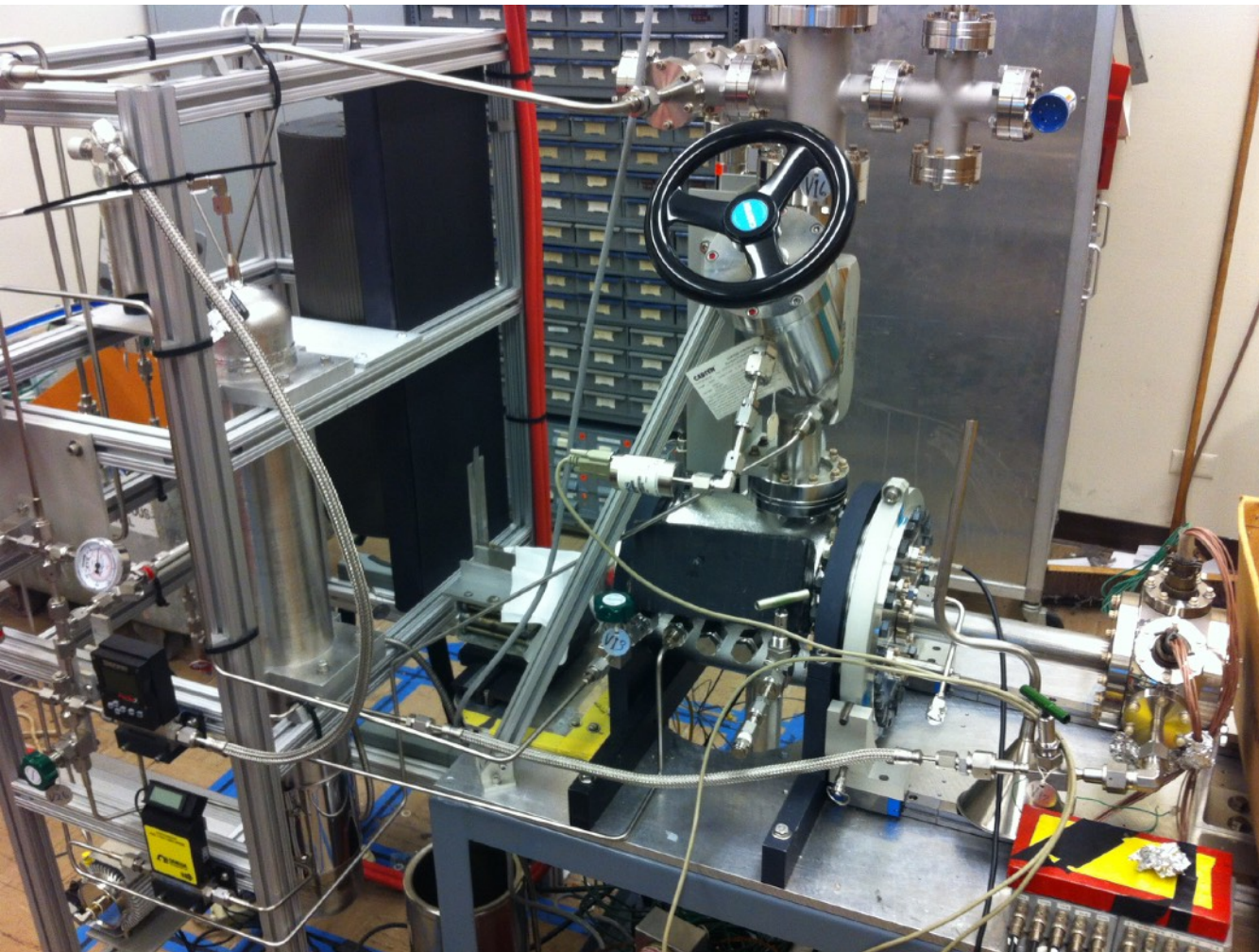


Working $\Sigma\Delta$ ADC

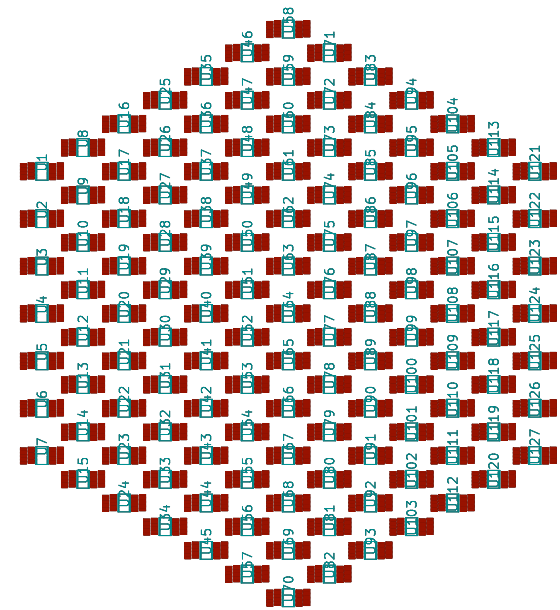


High pressure gas TPC prototype

Gas system

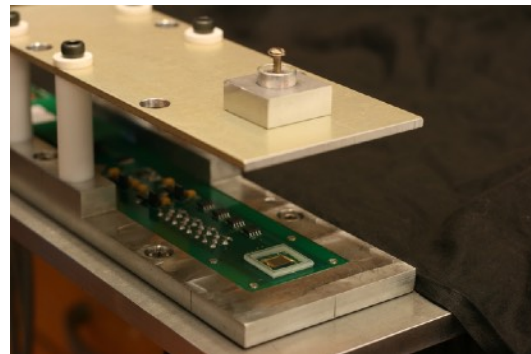
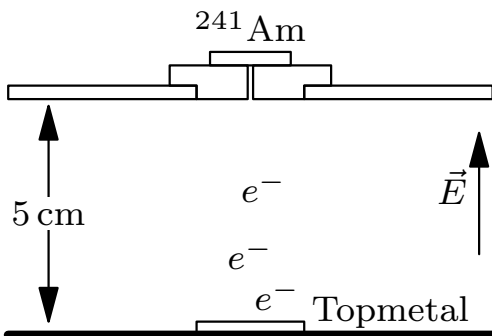
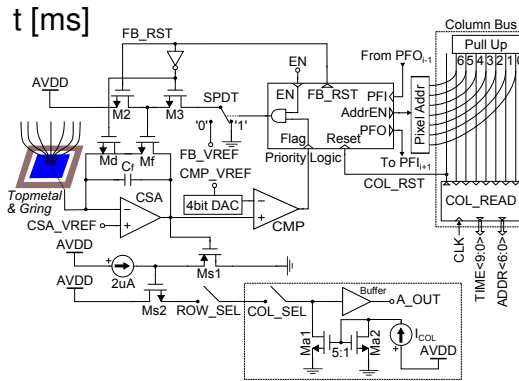
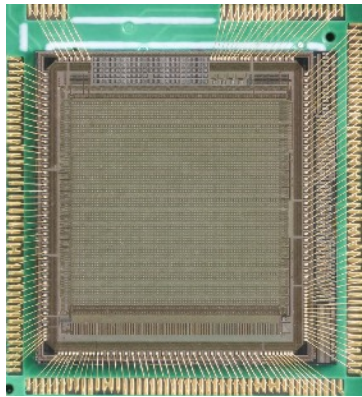
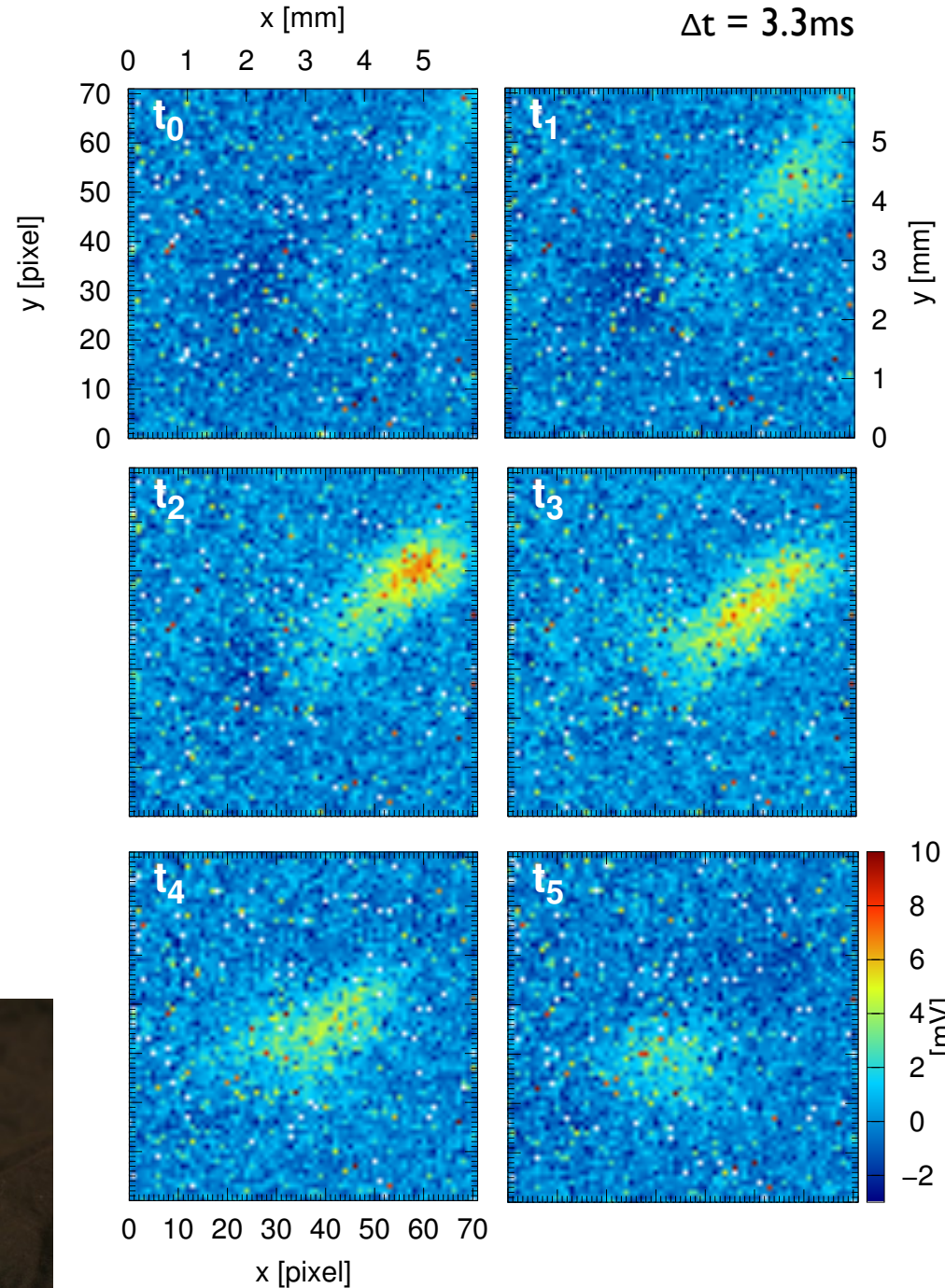
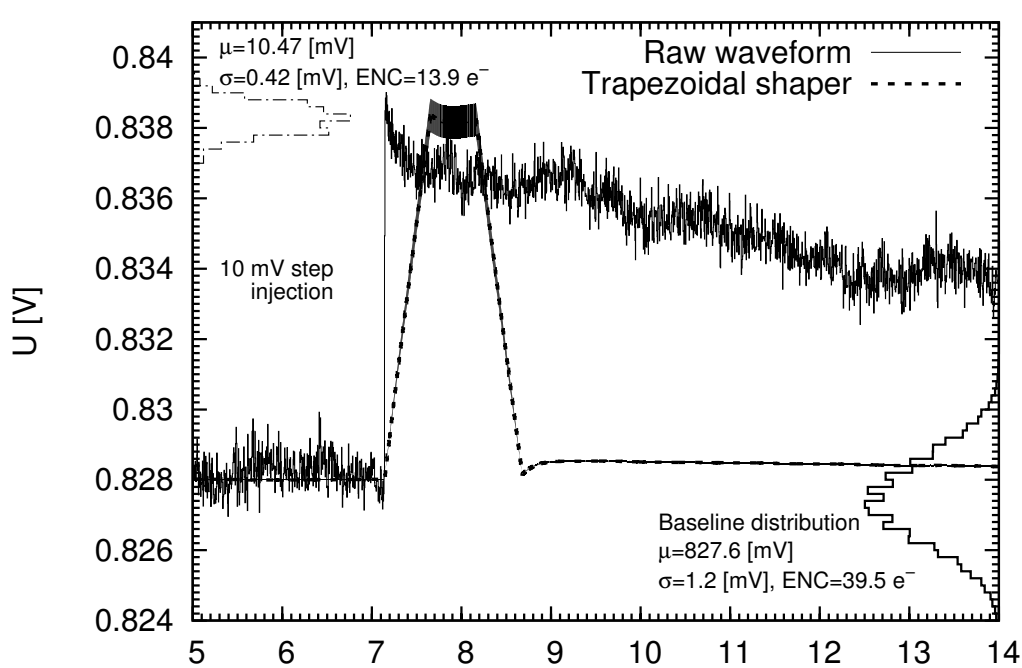


Charge plane:
127 chips, $\Phi 10\text{cm}$



- 1 mm dia. electrode
- 8mm pitch
- 127 chips on prototype

Topmetal-II seeing alpha (ion) tracks in air

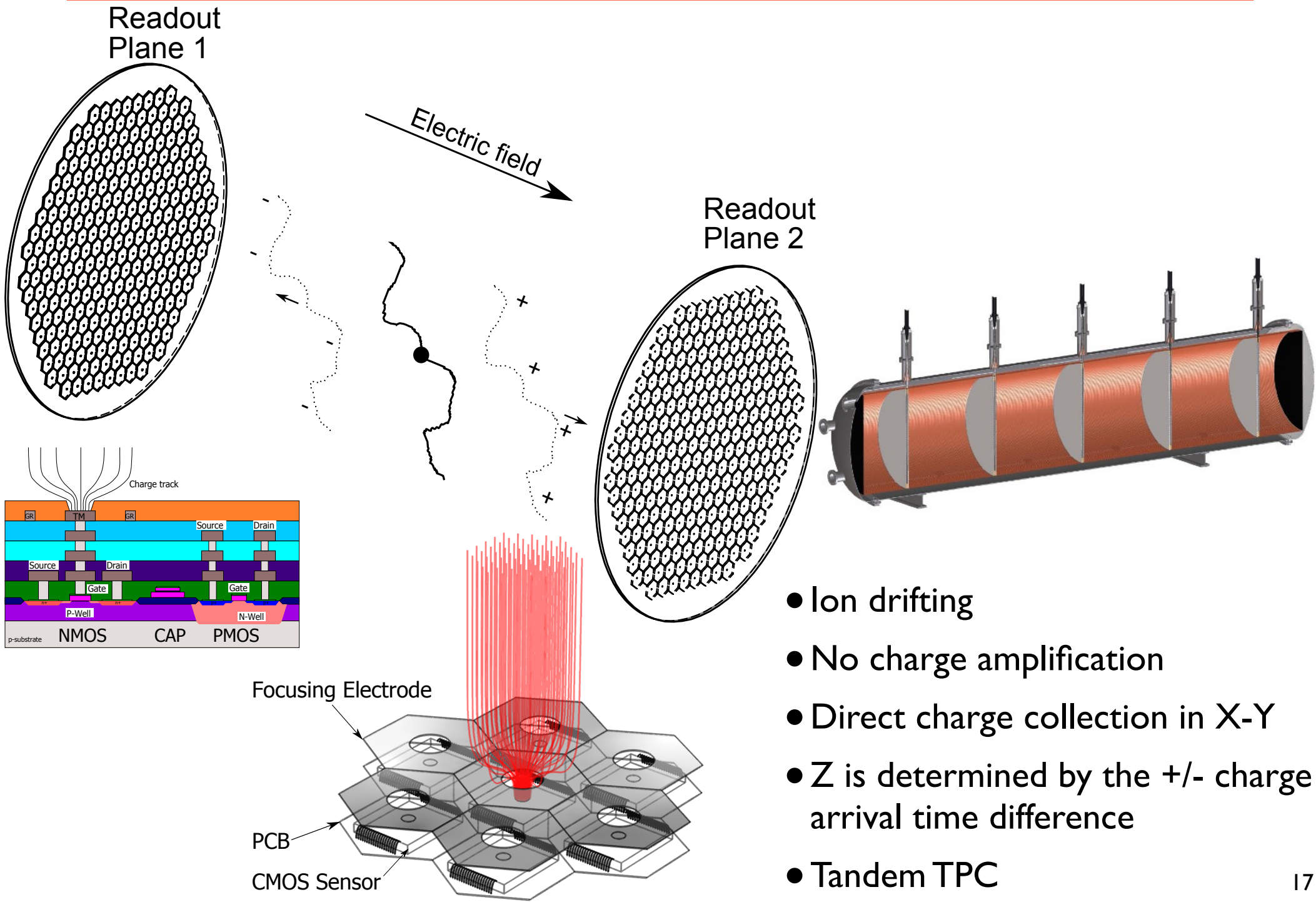


SeF₆ gas for $0\nu\beta\beta$ in ⁸²Se

- ⁸²Se
 - High $Q_{\beta\beta} \approx 2995.5\text{keV}$
 - $Q_{\beta\beta}$ for ¹³⁶Xe is 2458keV
 - A sharp drop in γ -ray backgrounds occurs above the ²⁰⁸Tl (2615keV) line
- SeF₆
 - Used in early days of HV electrical insulation
 - Easy to enrich ⁸²Se (9% natural abundance)
 - Low effective Z : straighter tracks – better tracking
 - Highly electronegative – ion drifting only
 - Cannot sustain well-behaved avalanche gain

Must detect ions directly in gas

Topmetal gain-less charge readout for $0\nu\beta\beta$ in $^{82}\text{SeF}_6$



Summary

- *Topmetal* direct charge sensor, without gas avalanche gain:
 - 1% FWHM energy resolution charge readout in HP Xe gas without sacrificing tracking
 - Very scalable leveraging electronics industry
 - Upgrade to PandaX-III, NEXT etc.
- Direct ion detection enables the use of SeF₆ gas
 - Provide an alternative isotope ⁸²Se.
 - Higher Q_{ββ} and better signal identification
 - Potential Xe/SeF₆ gas swap without modifying the rest of the system